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Dr. Hyo-Chang Lee is the Research Scientist at Korea Research Institute of Standards and Science (KRISS). He received Ph.D. degree from Hanyang University (2012). He worked at Hanyang University as lecture professor, research professor, and research fellow (2012-2015). During this period, he visited Princeton plasma physics laboratory as a visiting scientist (2013). He joined the division of Device Solutions (Semiconductor) at Samsung Electronics as a senior researcher (2015-2016). After that, he moved to the KRISS as a research scientist (2016-now). He published SCI papers more than 70 including Appl. Phys. Rev. 5, 011108 (2018) and a lot of patents. He is a senior member of IEEE and a board member of Korea vacuum society. His current research interests focus on the plasma metrology, source, processing and nano/bio applications.